

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	282	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor)	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:13
L2	277	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor) and (mixture or combination)	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:14
L3	108	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor) and (mixture or combination) and (water repell\$5 or hydrophobic\$5)	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:16
L4	108	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor) and (mixture or combination) and (water repell\$8 or hydrophobic\$5)	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:16
L5	76	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor) and (mixture or combination) and (water repell\$8 or hydrophobic\$5) and glass	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:18
L6	64	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor) and (mixture or combination) and (water repell\$8 or hydrophobic\$5) and glass and ("siO.sub.2" or silica or silicon dioxide)	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:23
L7	167	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor) and (mixture or combination) and glass and ("siO.sub.2" or silica or silicon dioxide)	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:24
L8	114	(hexamethyldisiloxane or HDMS) and (TEOS or tetraethoxysilane) and (TMDS or tetramethyldisiloxane) and (PECVD or plasma with CVD or plasma with vapor) and (mixture or combination) and glass and ("siO.sub.2" or silica or silicon dioxide) with (coat\$4 or film\$4 or layer\$4)	US-PGPUB; USPAT	ADJ	ON	2012/02/06 06:24
S1	2	(("20080241523") or ("20090214809")).PN.	US-PGPUB;	OR	OFF	2010/09/15 13:18

			USPAT; USOCR			
S2	4	("5800918" "6258156" "6340502" "6451432").PN.	US- PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2010/09/15 13:19
S3	1	("6482524").PN.	US- PGPUB; USPAT; USOCR	OR	OFF	2010/09/15 13:56
S4	4	("5328768" "5459198" "5550184" "5552476").PN. OR ("6482524").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 13:56
S5	26	(huignard arnaud or duran maxime).in.	US- PGPUB; USPAT; EPO	ADJ	ON	2010/09/15 13:56
S6	3	((("5324566") or ("4632842") or ("4983459"))).PN.	US- PGPUB; USPAT; USOCR	OR	OFF	2010/09/15 14:00
S7	8514	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4) with glass	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:18
S8	577	S7 and float	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:19
S9	74	S8 and glaz\$3	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:19
S10	4459	S7 and (silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:23
S11	612	S7 and (silicon or silicon dioxide or silicon oxide or "SiO.sub.2") same (sputter\$3 or plasma or PECVD)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:24
S12	313	S11 and activat\$6	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:24
S13	188	S12 and (fluoro\$6 or \$6silane)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:25
S14	191	S12 and (fluoro\$7 or \$6silane\$2)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:25
S15	3389	427/164,165,535,597.cds.	US- PGPUB; USPAT; USOCR;	ADJ	ON	2010/09/15 14:31

			FPRS			
S16	88	S15 and S7	US-PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2010/09/15 14:31
S17	59	S16 and (silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:35
S18	1	("5166000").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/09/15 14:38
S19	42	S16 and (silicon or silicon dioxide or silicon oxide or "SiO.sub.2") and plasma	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/15 14:57
S20	48	("4810564" "5010356" "5234718" "5240774" "5266222").PN. OR ("5580605").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 14:58
S21	8	("4368476" "4539061" "4673474" "4810564" "4863794" "4961996" "5328768" "5580605").PN. OR ("RE37698").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:00
S22	26	("2951862" "3012006" "3114760" "3127433" "3427336" "3579557" "4120995" "4539061" "4673474" "4724022" "4983459" "4992300" "4997684" "5011963" "5133895" "5328768" "5580605").PN. OR ("6503567").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:01
S23	76	("20020001676" "3637416" "3808027" "4118540" "4166891" "4263350" "4263371" "4274856" "4301197" "4478909" "4539061" "4547432" "4567221" "4711820" "4753827" "4838946" "4847160" "4946903" "4983459" "4997684" "5071709" "5234718" "5294252" "5300239" "5308705" "5320875" "5328768" "5372851" "5380585" "5383354" "5389427" "5413865" "5415927" "5435839" "5437894" "5463010" "5473037" "5476717" "5492762" "5525660" "5543171" "5580605" "5580606" "5583896" "5584917" "5596061" "5599625" "5599893" "5635246" "5665424" "5688864" "5691011" "5693236" "5723172" "5763091" "5800916" "5837644" "5840252" "5841931" "5846279" "5851674" "5873931" "5919296" "5973055" "6136444" "6245387").PN. OR ("6743516").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:02
S24	144	S23 or S22 or S21 or S20	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:02

S25	57	S24 and plasma	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:02
S26	2	((("6017609") or ("5997943")).PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/09/15 15:12
S27	40	("5266222" "5556667").PN. OR ("5997943").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:12
S28	8	("4814132" "5166000" "5324566").PN. OR ("6017609").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:13
S29	19	("4367388" "4539061" "5225274" "5250322" "5284707" "5324543" "5368892" "5380585" "5413865" "5415927" "5424130" "5510141" "5523161" "5545255" "5948476" "5997943").PN. OR ("6143417").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:16
S30	1	("4687707").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/09/15 15:19
S31	90	("3986997" "4211823" "4478873").PN. OR ("4687707").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/15 15:19
S33	14202	(uemura ryuzo or nishide toshikazu).in. or nissan.as.	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 08:14
S34	4	(uemura ryuzo or nishide toshikazu).in. and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 08:14
S35	25	("4125673" "4596745" "4830879" "4997684" "5137749").PN. OR ("5266358").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:16
S36	31	("3958073" "4948760" "5073195" "5250322" "5266358" "5268198" "5413865").PN. OR ("5674625").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:17
S37	54	("3859320" "3950588" "4024306" "4263371" "4276350" "4301197" "4529657" "4617057" "4724022" "4879345" "4944962" "4983459" "4997684" "5266358" "5294252" "5308705" "5314731" "5314947" "5328768" "5368892" "5413865" "5421866" "5424130" "5425804" "5489328" "5523161" "5523162").PN. OR ("5688864").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:18
S38	11	("3146122" "4087568" "4554177" "5266358" "5424130").PN. OR ("5693365").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:18

S39	52	("4568578" "4599272" "4919778" "5085926" "5201926" "5266358" "5271960" "5415794" "5514454" "5520996").PN. OR ("5776603").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:19
S40	39	("2526431" "3481756" "3758284" "3950588" "4263371" "4276350" "4301197" "4381204" "4529657" "4617057" "4724022" "4879345" "4983459" "4997684" "5221371" "5250322" "5266358" "5308705" "5314731" "5328768" "5368892" "5413865" "5421866" "5424130" "5425804" "5523161" "5523162" "5674967" "5688864" "5693365" "5707740").PN. OR ("6025025").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:20
S41	6	("4323489" "5266358" "5424130" "5523161" "6045961").PN. OR ("6623863").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:21
S42	168	S35 or S36 or S37 or S38 or S39 or S40 or S41	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:22
S43	67	S42 and (PECVD or plasma)	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:22
S44	52	("3640093" "3854961" "4361598" "4385086" "4386134" "4423112" "4476156" "4477499" "4581252" "4614673" "4636440" "4741778" "4789563" "4798629" "4801399" "4842837" "4842901" "4849378" "4966812" "4990377" "4997482" "5013588" "5035745" "5049414" "5053081" "5084356" "5091009" "5091224" "5096738" "5160455" "5175027" "5186745" "5196382" "5264197" "5266358" "5275796" "5281657" "5316699" "5318857" "5328645" "H000626").PN. OR ("5510147").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:23
S45	48	("4440822" "5318830" "5342676" "5387433").PN. OR ("5520996").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:25
S46	1	("5206060").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/09/16 08:27
S47	18	("4252837" "4382100" "4407852" "4508049" "4599266" "4612207" "4632844" "4693927" "4762730").PN. OR ("5206060").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 08:28
S48	100	S44 or S45	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 09:16
S49	42	S48 and (plasma or PECVD)	US-PGPUB;	ADJ	ON	2010/09/16 09:16

			USPAT; USOCR			
S50	24	("4983459" "4997684" "5308705" "5328768" "5368892").PN. OR ("5523162").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 09:24
S51	26	("4983459" "4997684" "5308705" "5328768" "5368892").PN. OR ("5523161").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 09:24
S52	33	("3127433" "3453232" "3950588" "4024306" "4263371" "4276350" "4301197" "4529657" "4549003" "4574149" "4617057" "4724022" "4879345" "4983459" "4997684" "5266358" "5308705" "5314731" "5328768" "5368892" "5413865" "5421866" "5424130" "5425804" "5523162").PN. OR ("5674967").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 09:25
S53	64	S50 or S51 or S52	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 09:32
S54	19493	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) same glass	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 09:37
S55	52811	("SiO.sub.2" or silicon dioxide or silica or metal oxide or metallic oxide) same (plasma or PECVD)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 09:38
S56	1092	S54 and S55	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 09:38
S57	289	S56 and (fluorine or fluorosilane or fluoro silane)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 09:41
S58	11	("5328768" "5413865").PN. OR ("6001485").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 09:45
S59	61	("3713869" "3856534" "4029842" "4081421" "4190681" "4239798" "4284685" "4301212" "4328646" "4341841" "4401500" "4544582" "4599272" "4632527" "4652497" "4743327" "4842941" "4927704" "5009920" "5030478" "5043390" "5124058" "5190807" "5206308" "5268217" "5298587" "5331487" "5382614" "5413865" "5415927" "5445871" "5446209" "5453539" "5476717" "5494742" "5508368" "5512374" "5550331" "5594231" "5622784" "5635245" "5643423" "5698266" "5707742" "5718967" "5744227" "5789071" "5846650" "5858536" "5873931" "5914151"	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 09:47

		"6001485" "6040053" "6111696" "6156389" "6160067").PN. OR ("6582823").URPN.				
S60	51	("5415927").URPN.	USPAT	ADJ	ON	2010/09/16 09:50
S61	22302	("SiO.sub.2" or silicon dioxide or silica or metal oxide or metallic oxide) same plasma same (air or oxygen or nitrogen or argon or hydrogen or "O.sub.2" or "N.sub.2" or "h.sub.2" or Ar or ammonia or "NH.sub.3" or fluorine or "SF.sub.6" or "CF.sub.4" or "C.sub.2" or "F.sub.6" or sulfur hexafluoride or hexafluoroethane or tetrafluoromethane)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 09:57
S62	685	S64 and S61	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 09:57
S63	2374	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) and S61	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:08
S64	1974	S63 and glass	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:09
S65	3396	427/164,165,535,597.ccls.	US- PGPUB; USPAT; USOCR; FPRS	ADJ	ON	2010/09/16 10:09
S66	24	S63 and glass and S65	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:09
S67	33	("5041304").URPN.	USPAT	ADJ	ON	2010/09/16 10:14
S68	81	("2553314" "3012006" "3244541" "3442664" "3579540" "3900672" "3959563" "4196246" "4267213" "4338377" "4410563" "4599272" "4609267" "4944962" "5061769" "5178955" "5225244" "T954010").PN. OR ("5622784").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 10:24
S69	55	S68 and plasma	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 10:25
S70	7	("5762697" "6204202" "6268457" "6368400" "6506497" "6586104").PN. OR ("6919106").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 10:31
S71	2914	saint gobain.as.	US- PGPUB; USPAT	ADJ	ON	2010/09/16 10:33
S72	243	S71 and glass and plasma	US- PGPUB; USPAT	ADJ	ON	2010/09/16 10:33
S73	20	("3890109" "4395467" "4793908"	US-	ADJ	ON	2010/09/16

		"4851095" "4920094" "4933058" "5122252" "5346600").PN. OR ("5569362").URPN.	PGPUB; USPAT; USOCR			10:35
S74	198	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) and S71	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:37
S75	190	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) and S71 and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:37
S76	44	S75 and plasma	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:37
S77	44	S75 and (plasma or ioniz\$3 with gas)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:37
S78	53	S75 and (plasma or ioniz\$3)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:37
S79	52	("4765729" "5328768" "5595825").PN. OR ("5800918").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/16 10:46
S80	1226	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) and (primer or sublayer or sub layer or priming) same (silica or "SiO.sub.2" or silicone dioxide or silicon oxide) and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:49
S81	658	S80 and (ioniz\$4 or plasma)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:50
S82	395	S81 not etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:50
S83	963	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) and (primer or sublayer or sub layer or priming) same (plasma or ioniz\$4) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide) and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:54
S84	166	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) same glass and (primer or sublayer or sub layer or priming) same (plasma or ioniz\$4) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/16 10:55
S85	90723	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) same (coat\$3 or film\$3 or layer\$3 or surface) and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 06:47

S86	190622	(plasma or ioniz\$3 near2 gas) same (air or oxygen or "O.sub.2" or argon or Ar or hydrogen or "h.sub.2" or ammonia) or ion near2 beam	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 06:49
S87	11678	S85 and S86	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 06:49
S88	4701	S87 not etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 06:50
S89	3	((("4983459") or ("4276350") or ("4301197"))).PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/09/23 06:54
S90	32	("4263371" "4276350" "4301197" "4529657").PN. OR ("4983459").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 06:55
S91	21	("3418153" "3420693" "3438760" "3558345" "3926604" "4086178" "4089804").PN. OR ("4276350").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 06:55
S92	23	("2184876" "2811408" "3616839" "3666614" "3808077" "3900617" "4027072" "4204025").PN. OR ("4301197").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 06:56
S93	58	S90 or S91 or S92	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 06:57
S94	20	S93 and (plasma or ion)	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 06:57
S95	25	("2951862" "3012006" "3114760" "3127433" "3427336" "3579557" "4120995" "4539061" "4673474" "4724022" "4983459" "4992300" "4997684" "5011963" "5133895" "5380585" "5580605").PN. OR ("6521334").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:03
S96	26	("2951862" "3012006" "3114760" "3127433" "3427336" "3579557" "4120995" "4539061" "4673474" "4724022" "4983459" "4992300" "4997684" "5011963" "5133895" "5328768" "5580605").PN. OR ("6503567").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:03
S97	28	S95 or S96	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:03
S98	6108	S87 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:06
S99	5959	S98 and (minutes or time)	US-	ADJ	ON	2010/09/23

			PGPUB; USPAT; FPRS			07:06
S100	60	S99 and plasma with (vapor or CVD) and fluorosilane	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:07
S101	61	S99 and (plasma with (vapor or CVD) or PECVD) and fluorosilane	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:07
S102	2737	S99 and (plasma with (vapor or CVD) or PECVD)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:11
S103	17424	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) same (coat\$3 or film\$3 or layer\$3 or surface) same (glass or transparent)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:13
S104	3056	S103 and S86	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:13
S105	1796	S104 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:13
S106	1745	S105 and (minutes or time)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:13
S108	871	S106 and (plasma with (vapor or CVD) or PECVD)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:14
S109	380	S106 and (plasma with (vapor or CVD) or PECVD)	USPAT	ADJ	ON	2010/09/23 07:16
S110	491	S106 and (plasma with (vapor or CVD) or PECVD)	US- PGPUB	ADJ	ON	2010/09/23 07:16
S111	2	((("5556667") or ("5250322")).PN.	US- PGPUB; USPAT; USOCR	OR	OFF	2010/09/23 07:31
S112	40	("4525213" "4648904" "4874431" "5051129" "5073195" "5196054").PN. OR ("5250322").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:32
S113	23	("2887412" "3920862" "4297396" "4341821" "4344991" "4396651" "4477486" "4479987" "4935264" "4976992" "4997684" "5075139" "5266358" "5370905" "5424130" "5500274" "Re25767").PN. OR ("5556667").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:33
S114	62	S112 or S113	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:33

S115	30	S114 and (ion or plasma)	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:33
S116	48	S103 and 427/535.ccls.	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 07:37
S117	1	("5413865").PN. OR ("6685992").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:41
S118	1	("5378527").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/09/23 07:45
S119	84	("4072782" "4400410" "4485146" "4504519" "4597844" "4636435" "4661409" "4777090" "4783361" "4907846").PN. OR ("5378527").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 07:47
S120	677	S103 and plasma same (fluorine or sulfur hexafluoride or "SF.sub.6" or "CF.sub.4" or "C.sub.2" "F.sub.6" or hexafluoroethane or hexa fluoroethane or tetreafluoromethane)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:04
S121	552	S120 and etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:05
S122	394	S121 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:05
S123	292	S103 and plasma same (fluorine or sulfur hexafluoride or "SF.sub.6" or "CF.sub.4" or "C.sub.2" "F.sub.6" or hexafluoroethane or hexa fluoroethane or tetreafluoromethane) same etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:09
S124	249	S123 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:09
S125	23577	plasma same (fluorine or sulfur hexafluoride or "SF.sub.6" or "CF.sub.4" or "C.sub.2" "F.sub.6" or hexafluoroethane or hexa fluoroethane or tetreafluoromethane) same etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:14
S126	249	S124 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:14
S127	18725	S125 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:16
S128	6447	S125 same (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:16

S129	17502	plasma with (fluorine or sulfur hexafluoride or "SF.sub.6" or "CF.sub.4" or "C.sub.2" "F.sub.6" or hexafluoroethane or hexa fluoroethane or tetreafluoromethane) same etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:17
S130	12636	plasma with (sulfur hexafluoride or "SF.sub.6" or "CF.sub.4" or "C.sub.2" "F.sub.6" or hexafluoroethane or hexa fluoroethane or tetreafluoromethane) same etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:17
S131	11415	plasma with (sulfur hexafluoride or "SF.sub.6" or "CF.sub.4" or "C.sub.2" "F.sub.6" or hexafluoroethane or hexa fluoroethane or tetreafluoromethane) with etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:17
S132	2748	S131 same (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:17
S133	8	S132 and 427/535.ccls.	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 08:18
S134	51	("5415927").URPN.	USPAT	ADJ	ON	2010/09/23 10:08
S135	310366	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:13
S136	846	float near3 glass and S135	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:13
S137	512	S136 and (bend\$3 or toughen\$3 or assembl\$3 or lamination)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:14
S138	336	S137 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:14
S139	19	S138 and molten with tin	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:14
S140	254	S138 and tin	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:15
S141	571	S136 and (bend\$3 or toughen\$3 or assembl\$3 or lamination or conversion)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:20
S142	460	S141 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2" or metal oxide)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:20
S143	351	S142 and tin	US-PGPUB;	ADJ	ON	2010/09/23 10:20

			USPAT; FPRS			
S144	26	S142 and tin same molten	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 10:20
S145	34	("2526431" "2699403" "3481756" "3758284" "3950588" "4263371" "4276350" "4301197" "4381204" "4529657" "4617057" "4724022" "4879345" "4983459" "4997684" "5221371" "5308705" "5314731" "5328768" "5368892" "5413865" "5421866" "5424130" "5425804" "5523161" "5523162" "5707740").PN. OR ("5980990").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 10:21
S146	33	("2526431" "3950588" "4263371" "4276350" "4301197" "4381204" "4529657" "4617057" "4724022" "4879345" "4983459" "4997684" "5308705" "5314731" "5328768" "5368892" "5413865" "5421866" "5424130" "5425804" "5523161" "5523162").PN. OR ("5707740").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 10:21
S147	42	S145 or S146	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 10:22
S148	8	S147 and float	US- PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 10:24
S149	525	S136 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:01
S150	68	S149 and plasma with (air or oxygen or "o.sub.2" or nitrogen or "n.sub.2" or argon or "h.sub.2" or ammonia)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:02
S151	1777	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) same glass and plasma with (air or oxygen or "o.sub.2" or nitrogen or "n.sub.2" or argon or "h.sub.2" or ammonia)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:05
S152	1007	S151 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:05
S153	645	S151 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2") and plasma same (clean\$3 or activat\$5)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:06
S154	460	S151 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2") and plasma with (clean\$3 or activat\$5)	US- PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:06
S155	63	S151 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2") and	US- PGPUB;	ADJ	ON	2010/09/23 11:10

		(fluorine with (silane or silicone) or fluorsilane or fluor silane)	USPAT; FPRS			
S156	8036	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or non wetting) and glass and plasma with (air or oxygen or "o.sub.2" or nitrogen or "n.sub.2" or argon or "h.sub.2" or ammonia)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:14
S157	305	S156 and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2") and (fluorine with (silane or silicone) or fluorsilane or fluor silane)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:14
S158	627	saint gobain.as. and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2")	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:54
S159	133	saint gobain.as. and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2") and glass and plasma	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:55
S160	6	saint gobain.as. and (mineral with silicon or silicon dioxide or silicon oxide or "SiO.sub.2") and glass and plasma same clean\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 11:55
S161	52	("4765729" "5328768" "5595825").PN. OR ("5800918").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 12:05
S162	1	("6461670").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2010/09/23 13:26
S163	7	("5314731" "5413865" "5808125" "6235833").PN. OR ("6461670").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 13:26
S164	60	float same glass same molten with tin same (bend\$3 or toughen\$3 or assembly\$3 or conversion or lamination\$4)	US-PGPUB; USPAT	ADJ	ON	2010/09/23 13:28
S165	19	("3453095" "3533888" "3630704" "3798013" "3990877").PN. OR ("4671814").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2010/09/23 13:41
S166	323	saint gobain.as. and float near2 glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 13:50
S167	58	saint gobain.as. and float near2 glass and tin with molten	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/23 13:50
S168	39	S167 and (bend\$3 or toughen\$3 or assembly\$3 or conversion or lamination\$4)	US-PGPUB; USPAT	ADJ	ON	2010/09/23 13:51
S169	534	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or non wetting) and (primer or sublayer or sub layer or priming) same (plasma or ionization\$4) and (silica or	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:31

		"SiO.sub.2" or silicone dioxide or silicon oxide) and glass and monitor\$3				
S170	115	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or nonwetting) same (glass or transparent or window) and (primer or sublayer or sub layer or priming) same (plasma or ionization\$4) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide) and monitor\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:32
S171	1812	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or nonwetting) with (glass or transparent or window) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide) and monitor\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:33
S172	569	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or nonwetting) with (glass or transparent or window) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide) and monitor\$3 and etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:35
S173	208	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or nonwetting) with (glass or transparent or window) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide or oxide) same etch\$3 and monitor\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:36
S174	29	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or nonwetting) with (glass or transparent or window) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide) and monitor\$3 same (roughen\$3 or etch\$3)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:42
S175	29	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or nonwetting) with (glass or transparent or window) and (silica or "SiO.sub.2" or silicon dioxide or silicon oxide) and monitor\$3 same (roughen\$3 or etch\$3)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:43
S176	42	((moisture or water) with repellent\$5 or hydrophobic\$4 or hydrophobic\$4 or nonwetting or nonwetting) with (glass or transparent or window) and monitor\$3 same (roughen\$3 or etch\$3)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:44
S177	3429	monitor\$3 same (roughen\$3 or etch\$3) same plasma	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:45
S178	2132	S177 and (silica or "SiO.sub.2" or silicon dioxide or silicon oxide)	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:45
S179	1630	S177 and (silica or "SiO.sub.2" or silicon dioxide or silicon oxide) same etch\$3	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:46

S180	1097	S177 and (silica or "SiO.sub.2" or silicon dioxide or silicon oxide) same etch\$3 same plasma	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:46
S181	472	S180 and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 06:46
S182	113	(silica or "SiO.sub.2" or silicon dioxide or silicon oxide) same (plasma with deposit\$3 or CVD or PECVD) same cold and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 07:30
S183	61	(silica or "SiO.sub.2" or silicon dioxide or silicon oxide) same (plasma with (deposit\$3 or CVD) or PECVD) same cold and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 07:32
S184	707	(silica or "SiO.sub.2" or silicon dioxide or silicon oxide) and (plasma with (deposit\$3 or CVD) or PECVD) same cold and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 07:33
S185	554	(silica or "SiO.sub.2" or silicon dioxide or silicon oxide) and (plasma with (deposit\$3 or CVD) or PECVD) same cold and glass same substrate	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 07:33
S186	1412	(silica or "SiO.sub.2" or silicon dioxide or silicon oxide) same (plasma with (deposit\$3 or CVD or vapor) or PECVD) and cold and glass same substrate	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 07:37
S187	425	(silica or "SiO.sub.2" or silicon dioxide or silicon oxide) same (plasma with (deposit\$3 or CVD or vapor) or PECVD) and cold same deposit\$3 and glass same substrate	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 07:37
S188	63	(silica or "SiO.sub.2" or silicon dioxide or silicon oxide) same (plasma with (deposit\$3 or CVD or vapor) or PECVD) and cold near2 plasma and glass	US-PGPUB; USPAT; FPRS	ADJ	ON	2010/09/27 07:43
S189	25	glass ceramic with sodium silicate	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/04/05 13:00
S190	3	("5250322" "5523161").PN. OR ("6340502").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:34
S191	59	("4765729" "5328768" "5595825").PN. OR ("5800918").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:34
S192	41	("4525213" "4648904" "4874431" "5051129" "5073195" "5196054").PN. OR ("5250322").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:35
S193	26	("4983459" "4997684" "5308705" "5328768" "5368892").PN. OR ("5523161").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:35
S194	23	("20020082329" "3579540" "3986997" "4983459" "4997684" "5071709"	US-PGPUB;	ADJ	ON	2011/04/05 13:35

		"5324566" "5328768" "5360851" "5425804" "5449712" "5523161" "5523162" "5571622" "5800918" "5840800" "5889086" "5997943" "6001485" "6025025" "6099971" "6340502").PN. OR ("7344783").URPN.	USPAT; USOCR			
S195	149	S189 or S190 or S191 or S192 or S193 or S194	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:37
S196	0	S195 and vacuum cathode sputter\$3	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:37
S197	44	vacuum cathode sputter\$3	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:37
S198	329	vacuum with cathode with sputter\$3 same2 (silica or "SiO.sub.2" or silicon dioxide or silicon oxide os "SiO.sub.x")	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:39
S199	304	vacuum with cathode with sputter\$3 same2 (silica or "SiO.sub.2" or silicon dioxide or silicon oxide os "SiO.sub.x")	US- PGPUB; USPAT	ADJ	ON	2011/04/05 13:40
S200	262	S199 and glass	US- PGPUB; USPAT	ADJ	ON	2011/04/05 13:40
S201	227	S199 and glass with substrate	US- PGPUB; USPAT	ADJ	ON	2011/04/05 13:40
S202	2	((("5328768") or ("5523162"))).PN.	US- PGPUB; USPAT; USOCR	OR	OFF	2011/04/05 13:46
S203	24	("4983459" "4997684" "5308705" "5328768" "5368892").PN. OR ("5523162").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:46
S204	81	("2553314" "3950588" "4180618" "4188444" "4263371" "4276350" "4301197" "4472510" "4478909" "4529657" "4816333" "4879345" "4983459" "4997684" "5071709").PN. OR ("5328768").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:46
S205	212	S195 or S203 or S204	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:46
S206	137	S205 and glass with (ceramic or laminated or monolithic)	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:47
S207	35	S206 and (RMS or roughness)	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:49
S208	35	S206 and (RMS or roughness or root mean)	US- PGPUB;	ADJ	ON	2011/04/05 13:49

			USPAT; USOCR			
S209	18	("5523161" "5651921" "5674625" "5707740" "5814397" "5856016").PN. OR ("6210750").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:50
S210	18	S205 and ceramic glass	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 13:53
S211	591	(huignard arnaud or duran maxime).in. or (saint-gobain glass).as.	US- PGPUB; USPAT; FPRS; EPO; JPO	ADJ	ON	2011/04/05 13:56
S212	262	S211 and (silica or "SiO.sub.2" or silicon dioxide or silicon oxide os "SiO.sub.x")	US- PGPUB; USPAT; FPRS; EPO; JPO	ADJ	ON	2011/04/05 13:57
S213	158	S212 and sputter\$3	US- PGPUB; USPAT; FPRS; EPO; JPO	ADJ	ON	2011/04/05 13:57
S214	63	(huignard arnaud or duran maxime).in. or (saint-gobain glass).as.	EPO; JPO	ADJ	ON	2011/04/05 13:59
S215	46	("4539061" "4761316" "4842917" "4863794" "4865910" "4902585" "4992300" "5011727" "5011963" "5143750").PN. OR ("5324566").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 14:09
S216	8	("4814132" "5166000" "5324566").PN. OR ("6017609").URPN.	US- PGPUB; USPAT; USOCR	ADJ	ON	2011/04/05 14:18
S217	1	("20020064663").PN.	US- PGPUB; USPAT; USOCR	OR	OFF	2011/04/05 14:20
S218	8541	(hydrophobic or water repellen\$4 or nonwett\$5 or non wett\$5) with glass	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/05 14:42
S219	50943	\$3layer\$3 near2 (mineral or anchor\$5 or primer or priming or metal oxide)	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/05 14:43
S220	582	S218 and S219	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/05 14:44
S221	525	S220 and (al or aluminum)	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/05 14:44
S222	365	S220 and (aluminum)	US-	ADJ	ON	2011/04/05

			PGPUB; USPAT; FPRS			14:49
S223	305	S220 and (aluminum or al) same (silicon or silica or Si or "SiO.sub.2" or "SiO.sub.x")	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/05 14:53
S224	8547	(hydrophobic or water repellen\$4 or nonwett\$5 or non wett\$5) with glass	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:33
S225	50973	\$3layer\$3 near2 (mineral or anchor\$5 or primer or priming or metal oxide)	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:33
S226	0	S224 and S225 and fluorine and weight near2 area	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:33
S227	0	S224 and S225 and weight near2 area	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:34
S228	255	S224 and S225 and fluorine	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:34
S229	130	S224 and S225 and (fluorine or F) same (weight or wt or "wt%")	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:39
S230	100	S224 and S225 and (fluorine or Fluoro\$8) same (weight or wt or "wt%")	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:40
S231	48	S224 and S225 and (fluorine or Fluoro\$8) same (weight or wt or "wt%" or amount or concentration) same (sufficient or effective or desired or required)	US- PGPUB; USPAT; FPRS	ADJ	ON	2011/04/08 09:43
S232	131	vacuum with cathode with sputter\$3 same2 (silica or "SiO.sub.2" or silicon dioxide or silicon oxide os "SiO.sub.x") and glass and (cold or low with temperature)	US- PGPUB; USPAT	ADJ	ON	2011/04/11 07:43
S233	34	vacuum cathode sputter\$4	US- PGPUB; USPAT	ADJ	ON	2011/04/11 07:44
S234	2863	204/192.12,192.22,192.23.cds.	US- PGPUB; USPAT	ADJ	ON	2011/04/11 08:05
S235	346	S234 and vacuum and ((room or low) with temperature or cold) and cathode with sputter\$4	US- PGPUB; USPAT	ADJ	ON	2011/04/11 08:05
S236	226	S235 and oxide	US- PGPUB; USPAT	ADJ	ON	2011/04/11 08:05
S237	138	S236 and glass	US- PGPUB; USPAT	ADJ	ON	2011/04/11 08:06

S238	6294	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) with (glass or transparent or window) and (silica or "SiO.sub.2" or silicone dioxide or silicon oxide or "SiO.sub.x")	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/04/11 09:27
S239	5168	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) with glass and (silica or "SiO.sub.2" or silicon dioxide or silicon oxide or "SiO.sub.x")	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/04/11 09:28
S240	3187	427/164,165,535,597.ccls.	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/04/11 09:28
S241	56	S239 and S240	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/04/11 09:28
S242	2875	204/192.12,192.22,192.23.ccls.	US-PGPUB; USPAT	ADJ	ON	2011/05/20 09:58
S243	3213	427/164,165,535,597.ccls.	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/05/20 09:58
S244	6053	S242 or S243	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/05/20 09:58
S245	5209	((moisture or water) with repellen\$5 or hydrophobic\$4 or hydro phobic\$4 or nonwetting or non wetting) with glass and (silica or "SiO.sub.2" or silicon dioxide or silicon oxide or "SiO.sub.x")	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/05/20 09:59
S246	67	S244 and S245	US-PGPUB; USPAT; FPRS	ADJ	ON	2011/05/20 09:59
S249	1170	("C.sub.2" "F.sub.6" or hexafluoroethane) with (gas or plasma) and ("SiO.sub.2" or silicon dioxide or silica) same (roughen\$4 or etch\$4)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 07:10
S250	841	S249 and (oxygen or "O.sub.2") same gas	US-PGPUB; USPAT	ADJ	ON	2012/02/02 07:10
S251	2989	204/192.12,192.22,192.23.ccls.	US-PGPUB; USPAT	ADJ	ON	2012/02/02 07:11
S252	3366	427/164,165,535,597.ccls.	US-PGPUB; USPAT; FPRS	ADJ	ON	2012/02/02 07:11
S253	6319	S251 or S252	US-PGPUB; USPAT; FPRS	ADJ	ON	2012/02/02 07:11
S254	15	S250 and S253	US-PGPUB;	ADJ	ON	2012/02/02 07:11

			USPAT			
S255	12	S250 and RMS	US-PGPUB; USPAT	ADJ	ON	2012/02/02 07:13
S256	1170	("C.sub.2" "F.sub.6" or hexafluoroethane) with (gas or plasma) and ("SiO.sub.2" or silicon dioxide or silica) same (roughen\$4 or etch\$4)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:27
S257	841	S256 and (oxygen or "O.sub.2") same gas	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:27
S258	9	S257 and (RMS or root mean square) with (etch\$4 or rough\$5)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:27
S259	10	S256 and (RMS or root mean square) with (etch\$4 or rough\$5)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:29
S260	19	S256 and (RMS or root mean square)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:30
S261	441	("C.sub.2" "F.sub.6" or hexafluoroethane) with (gas or plasma) same ("O.sub.2" or oxygen) and ("SiO.sub.2" or silicon dioxide or silica) with (roughen\$4 or etch\$4)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:30
S262	16	S261 and hydrophobic	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:32
S263	250	("C.sub.2" "F.sub.6" or hexafluoroethane) same ("O.sub.2" or oxygen) and ("SiO.sub.2" or silicon dioxide or silica) with (roughen\$4 or etch\$4) with plasma	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:35
S264	23	("4330384").PN. OR ("4465552").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 09:39
S265	62	S263 and (oxygen or "O.sub.2") with (volume or volume% or concentration)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:43
S266	6	("C.sub.2" "F.sub.6" or hexafluoroethane) same ("O.sub.2" or oxygen) and ("SiO.sub.2" or silicon dioxide or silica) with rough\$6 same plasma	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:55
S267	9	("C.sub.2" "F.sub.6" or hexafluoroethane) and ("O.sub.2" or oxygen) and ("SiO.sub.2" or silicon dioxide or silica) with rough\$6 same plasma	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:55
S268	9	("C.sub.2" "F.sub.6" or hexafluoroethane) and ("O.sub.2" or oxygen) and ("SiO.sub.2" or silicon dioxide or silica) with rough\$10 same plasma	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:55
S269	28	("C.sub.2" "F.sub.6" or hexafluoroethane) and ("O.sub.2" or oxygen) and ("SiO.sub.2" or silicon dioxide or silica) same rough\$10 same plasma	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:56
S270	12	("C.sub.2" "F.sub.6" or hexafluoroethane) with plasma and ("SiO.sub.2" or silicon dioxide or silica) same rough\$10 same plasma	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:57

S271	2989	204/192.12,192.22,192.23.ccls.	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:58
S272	3366	427/164,165,535,597.ccls.	US-PGPUB; USPAT; FPRS	ADJ	ON	2012/02/02 09:58
S273	6319	S271 or S272	US-PGPUB; USPAT; FPRS	ADJ	ON	2012/02/02 09:58
S274	12	("C.sub.2" "F.sub.6" or hexafluoroethane) with plasma and ("SiO.sub.2" or silicon dioxide or silica) and S273	US-PGPUB; USPAT	ADJ	ON	2012/02/02 09:58
S275	199	("C.sub.2" "F.sub.6" or hexafluoroethane) with plasma same ("SiO.sub.2" or silicon dioxide or silica)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 10:44
S276	161	("C.sub.2" "F.sub.6" or hexafluoroethane) with plasma same ("SiO.sub.2" or silicon dioxide or silica) and ("O.sub.2" or oxygen)	US-PGPUB; USPAT	ADJ	ON	2012/02/02 10:44
S277	23	("4330384").PN. OR ("4465552").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:45
S278	41	("3246949" "3679502" "3880684" "3923568" "3940506" "3971684" "3994793" "4017548" "4026742" "4052251" "4069096" "4094732" "4214946" "4263467" "4283249" "4310380" "4314875" "4324611" "4330384" "4364793" "4381967" "4405406" "4442338" "4450042" "4465552" "4473435" "4479850").PN. OR ("4582581").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:46
S279	16	("4496448" "4640737" "4786361" "4798650" "4844767").PN. OR ("5147500").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:51
S280	27	("4226665" "4547260" "4676867").PN. OR ("5173151").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:52
S281	11	("4563367" "4581101" "5174856" "5266153" "5300460" "5626775").PN. OR ("6209483").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:54
S283	39	(S277 or S278 or S279 or S280 or S281) and ("C.sub.2" "F.sub.6" or hexafluoroethane)	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:56
S284	32	S283 and ("SiO.sub.2" or silica or silicon dioxide)	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:56
S285	27	S283 and ("SiO.sub.2" or silica or silicon dioxide) and (oxygen or "O.sub.2")	US-PGPUB; USPAT; USOCR	ADJ	ON	2012/02/02 10:57

EAST Search History (Interference)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S247	17	(huignard arnaud or duran maxime).in.	US-PGPUB; USPAT; UPAD	ADJ	ON	2011/05/20 10:00
S248	9	S247 and plasma.cdm.	US-PGPUB; USPAT; UPAD	ADJ	ON	2011/05/20 10:00
S286	22	(huignard arnaud or duran maxime).in.	US-PGPUB; USPAT; UPAD	ADJ	ON	2012/02/02 10:23
S287	10	(huignard arnaud or duran maxime).in. and (plasma).cdm.	US-PGPUB; USPAT; UPAD	ADJ	ON	2012/02/02 10:23

2/ 6/ 2012 7:29:15 AM
C:\Users\mwieczorek\Documents\EAST\Workspaces\10590197.wsp